today a Gupla

## JAYPEE UNIVERSITY OF INFORMATION TECHNOLOGY, WAKNAGHAT TEST 1 EXAMINATION - September 2017

B.Tech ECE 3<sup>rd</sup> Semester

COURSE CODE: 10B11EC312

MAX. MARKS: 15

COURSE NAME: Analog Electronics

MAX. TIME: 1HR

COURSE CREDITS: 4

Note: All questions are compulsory. Carrying of mobile phone during examinations will be treated as case of unfair means.

- Q1. (a). Explain why the depletion region extends deeper into the lightly doped region of the PN- Diode.
  - (b). Define following terms
    - i. Critical temperature
    - ii. Fermi level
    - iii. Diffusion length

[1+1+1]

[2]

- Q2.(a) A stream of excess holes is injected at x=0. Prove that excess hole concentration decreases exponentially in positive x- direction due to recombination. [2.5]
  - (b). Derive the expression of contact potential under equilibrium in terms of concentration of holes on each side of the junction. [2.5]
- Q3. An abrupt Si PN- junction has  $N_a=10^{15}/cm^3$ ,  $N_d=10^{17}/cm^3$ ,  $n_i=10^{10}/cm^3$ ,  $\epsilon_r=11.8~m_n^*=1.1m_0$ ,  $m_p^*=0.56m_0$ , where  $m_0$  is rest mass of electron. At 300K, calculate the Fermi level position for both sides of the junction, draw the equilibrium band diagram and find  $V_0$  from the band diagram. If diode has a circular cross-section with diameter of 5  $\mu$ m, sketch E(x). [5]

EC-1, BT